Interaction of Formamide with the Ru(001) Surface

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Abstract: The adsorption and decomposition of formamide (NH₂CHO) on the hexagonally close-packed Ru(001) surface have been studied by using high-resolution electron energy loss spectroscopy and thermal desorption mass spectrometry. At 80 K, the initial adsorption of formamide results in CH bond cleavage and the formation of an $\eta^2(C,O)$ -NH₂CO species. This species decomposes upon annealing to 250 K, leaving a mixture of CO, NH₃, NH, and hydrogen adatoms on the surface. The NH₃ and CO desorb near 315 and 480 K, respectively, whereas the NH decomposes below 400 K to nitrogen and hydrogen adatoms. Recombinative desorption of H₂ occurs at 420 K, while recombinative desorption of N₂ occurs near 770 K. For higher initial formamide coverages (where the fractional coverage of formamide that decomposes exceeds approximately 0.05 monolayer), molecular adsorption in an $\eta^1(O)$ -NH₂CHO configuration is observed also at 80 K. This species undergoes competing desorption and decomposition at 225 K to an intermediate believed to be N-bonded NHCHO, which in turn converts to a species tentatively identified as $\eta^1(N)$ -NCHO at 300 K. The latter species decomposes to chemisorbed CO, N, and H near 375 K. Following a saturation formamide exposure on Ru(001) at 80 K, approximately 0.15 monolayer of formamide decomposes upon subsequent annealing, with approximately two-thirds of the total decomposing via the $\eta^2(C,O)$ -NH₂CO intermediate and the remainder reacting via the $\eta^1(O)$ -NH₂CHO.

I. Introduction

High-resolution electron energy loss spectroscopy (EELS) has emerged as one of the most important experimental techniques for studying the reactions of molecules on well-characterized metal surfaces,¹ especially in delimiting reaction mechanisms via the isolation of reaction intermediates. Such studies are of interest not only because of the obvious importance of understanding molecule-metal surface interactions in heterogeneous catalytic processes but also because they allow comparisons to be made between the bonding and reactivity of various ligands in multinuclear homogeneous metal clusters and that on metal surfaces. Recently, we have reported the results of an EELS and thermal desorption mass spectrometric (TDMS) study of the interaction of formamide (NH₂CHO) with the Ru(001)-p(1×2)-O surface, i.e., the hexagonally close-packed ruthenium surface on which an ordered $p(1 \times 2)$ overlayer of oxygen adatoms (fractional coverage of one-half) is present.² We report here the results of an EELS and TDMS study of the adsorption and decomposition of formamide on the clean (reduced) Ru(001) surface.

From the point of view of chemisorption, formamide is a rather complex molecule, containing two heteroatoms and a carbonyl double bond. Thus, there are several ways that formamide might adsorb molecularly on a metal surface: via the electron lone pairs on the oxygen and/or nitrogen atoms (although in gas-phase formamide there is no electron lone pair isolated strictly on the nitrogen atom), or in an $\eta^2(C,O)$ configuration with rehybridization of the carbonyl double bond. A number of decomposition intermediates are also possible, as may be appreciated by considering the variety of formamide-derived ligands that have been identified in organometallic compounds. These include $\eta^1(C)$ -CONHR,³ η^1 (N)-NHCOR,⁴ η^2 (C,O)-NR₂CO,⁵ η^2 (N,O)-NRCHO (both chelating and bridging),⁶ and the tautomers η^2 -(C,N)-HOCNR and η^2 (C,N)-OCNHR (R = H, alkyl, or aryl).⁷ These species are depicted schematically in Figure 1 with R =H, the case relevant to formamide decomposition on a metal surface.

In our study of formamide chemisorption on the Ru(001)-p- (1×2) -O surface,² it was found that below 225 K formamide bonds to the surface via a lone pair of electrons on the oxygen atom, i.e., the formamide adsorbs molecularly below 225 K in an η^1 -(O)-NH₂CHO configuration. At 225 K, the η^1 (O)-NH₂CHO converts to $\eta^2(N,O)$ -NH₂CHO that is bonded to the surface via electron lone pairs on both the oxygen and nitrogen atoms. The $\eta^2(N,O)$ -NH₂CHO converts near 260 K to $\eta^2(N,O)$ -NHCHO,

the nitrogen-containing analogue of the η^2 -formate that has been identified previously on Ru(001) as an intermediate in the decomposition of formic acid.⁸ For sufficiently high initial formamide coverages, both of these conversions are accompanied by some molecular desorption of formamide. The $\eta^2(N,O)$ -NHCHO is stable on the Ru(001)-p(1×2)-O surface to 420 K, at which temperature it decomposes, evolving gaseous CO and H₂ and leaving nitrogen adatoms on the surface. The nitrogen adatoms recombine and desorb as N₂ near 570 K, leaving the $p(1 \times 2)$ -O overlayer intact. For a saturation formamide exposure, approximately 0.05 monolayer of $\eta^2(N,O)$ -NHCHO is formed and decomposes on this surface. (A monolayer is defined as 1.58×10^{15} cm^{-2} , the density of ruthenium atoms on the Ru(001) surface.)

Electronegative adsorbates such as oxygen adatoms can alter the chemical reactivity of metal surfaces, just as electron-withdrawing ligands modify the properties and reactivity of organometallic compounds. Comparing the reactions of formamide on the Ru(001)-p(1×2)-O surface and on clean Ru(001) is of particular interest in view of the fact that ordered oxygen over-

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Figure 1. Several possible decomposition products of formamide on a metal surface. All of these species have known organometallic analogues (in some of which one or both hydrogens are replaced by an alkyl or aryl group).

layers are known to alter the chemistry of both acetone⁹ and formaldehyde¹⁰ on Ru(001). On clean Ru(001), both acetone and formaldehyde adsorb at 80 K principally via rehybridization of the CO double bond in an $\eta^2(C,O)$ configuration. In the case of formaldehyde, some decomposition to CO, $\eta^2(C,O)$ -HCO, and hydrogen adatoms occurs as well. On the $Ru(001)-p(2\times 2)-O$ surface, adsorption at 80 K of both molecules occurs primarily in an $\eta^1(O)$ configuration, with bonding to the surface occurring via an electron lone pair on the oxygen atom. Thus, in the case of the adsorption of formamide on clean Ru(001) at 80 K, we might expect the formation of $\eta^2(C,O)$ -NH₂CHO or $\eta^2(C,O)$ -NH₂CO, rather than the formation of $\eta^1(O)$ -NH₂CHO, which occurs on the Ru(001)-p(1×2)-O surface. Such species could also lead to different decomposition products compared to those from $\eta^1(O)$ -NH₂CHO.

II. Experimental Details

The EEL spectrometer and the ultrahigh vacuum (UHV) chamber housing it have been described elsewhere, 11 as have the methods of cleaning the Ru(001) crystal¹² and handling the formamide.² Typical parameters for the EEL spectra shown and discussed in this paper are the following: resolution (full-width at half-maximum of the elastically scattered electron beam), 70-80 cm⁻¹; count rate (elastically scattered peak), 2×10^5 Hz; impact energy of the incident electron beam, 4 eV; and (fixed) angle of incidence of the electron beam, 60° with respect to the surface normal. All EEL spectra were measured in the specular direction, except when it is stated explicitly otherwise. The UHV chamber also contained a quadrupole mass spectrometer for performing TDMS measurements and for an analysis of background gases. The heating rate in all thermal desorption spectra was approximately 8 K·s⁻¹ The base pressure in the UHV chamber was less than 10⁻¹⁰ Torr. Liquid nitrogen cooling allowed crystal temperatures as low as 80 K to be attained. The crystal was heated resistively and cleaned by annealing in a background of oxygen or, occasionally, by argon ion sputtering.

The NH₂CHO used in this study was obtained from Aldrich with a reported purity of 99% and was purified further as discussed elsewhere.² Its purity was verified in situ with mass spectrometry. Both EELS and TDMS experiments were also performed with N-deuteriated formamide, ND₂CHO (MSD Isotopes, 98 at % D). Although H/D exchange into



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Figure 2. The molecular formamide (m/e = 45 amu) thermal desorption spectra that result following various exposures of NH2CHO to the clean Ru(001) surface at 80 K. The approximate formamide exposures are (a) 2 L, (b) 4 L, (c) 6 L, (d) 8 L, and (e) 12 L.

the ND₂ group resulted in the presence of small amounts of NHDCHO and/or NH2CHO in the ND2CHO,13 these experiments were nevertheless useful in helping to assign various EELS loss features, and they also yielded qualitative information concerning H₂ thermal desorption.

III. Results

A. Thermal Desorption Mass Spectrometry. Following a saturation exposure of formamide on the clean Ru(001) surface at 80 K, five different species are observed to desorb between approximately 200 and 800 K, namely, molecular formamide, carbon monoxide, hydrogen, nitrogen, and ammonia.¹⁴ Species specifically looked for and not observed to desorb include H₂O, HCN, NO, and H₂CO. The five molecular species detected with TDMS are discussed separately below.

1. Molecular Formamide. Figure 2 shows a series of thermal desorption spectra of NH₂CHO (m/e = 45 amu) following various exposures of formamide to the clean Ru(001) surface at 80 K. For exposures less than approximately 4 L (1 L = 1 Langmuir $= 10^{-6}$ Torr·s), no molecular desorption occurs, indicating that at low coverages all of the adsorbed formamide decomposes. For exposures greater than approximately 4 L, a molecular desorption peak appears at 225 K. The peak temperature does not shift with increasing exposures (i.e., coverage), indicative of a first-order desorption reaction. Assuming a preexponential factor of the desorption rate coefficient of 10^{13} s⁻¹, an activation energy of desorption (equal to the heat of adsorption since adsorption is not activated) of approximately 13 kcal·mol⁻¹ is calculated for this desorption state.¹⁵ This desorption feature is most likely due to monolayer rather than second layer formamide,² especially since the amount of formamide that decomposes (approximately 0.15 monolayer, cf. Section III.A.2) seems very low to correspond to monolayer saturation. For exposures greater than approximately 8 L, a second thermal desorption peak appears at 210 K. This peak does not saturate with increasing exposure and is due to the desorption of condensed formamide multilayers, in agreement with previous results for formamide desorption from the Ru(001)-p- (1×2) -O surface.²

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⁽¹³⁾ The exchange of hydrogen into the ND_2 group of ND_2CHO may occur in the metal line through which formamide is passed before entering the UHV chamber or on the walls of the UHV chamber.

⁽¹⁴⁾ Since the amount of ammonia desorbed is very small, it was difficult to detect via TDMS in the EELS chamber, and these TDMS experiments were carried out in a companion UHV chamber in which the mass spectrometer is closer to the crystal. The production of ammonia was also dem-onstrated unambiguously by EELS. For previous TDMS results concerning ammonia on Ru(001), see: (a) Benndorf, C.; Madey, T. E. Surf. Sci. 1983, 135, 164. (b) Danielson, L.; Dresser, M. J.; Donaldson, E. E.; Dickinson, J. T. Surf. Sci. 1978, 71, 599. In ref 14a, the saturation (monolayer) coverage of ammonia on Ru(001) was estimated to be 0.25 monolayer. (15) Redhead, P. A. Vacuum 1962, 203.



Figure 3. Thermal desorption spectra of CO (m/e = 28 amu) that result following various exposures of NH₂CHO to the clean Ru(001) surface at 80 K. The approximate formamide exposures are (a) 0.3 L, (b) 1 L, (c) 5 L, and (d) 10 L.

2. Carbon Monoxide. Thermal desorption spectra of CO (m/e)= 28 amu) following various exposures of NH_2CHO to Ru(001)at 80 K are shown in Figure 3. There is a single CO thermal desorption peak that occurs at 480 K for the lowest exposures studied (fractional surface coverage of CO desorbed of approximately 0.01 monolayer) and shifts downward to 410 K at saturation. Despite this downshift in peak temperature with increasing coverage, this is a first-order, desorption-limited reaction, since low coverages of chemisorbed CO on clean Ru(001) also desorb near 480 K,¹⁶ the recombinative desorption of CO formed from carbon and oxygen adatoms occurs only above 500 K on this surface,¹⁷ and EEL spectra show clearly that molecularly adsorbed CO is present from 250 to above 400 K (cf. Section III.B). The most reasonable cause of the downshift in the CO desorption temperature with increasing formamide exposures is the increasing coverage of nitrogen adatoms between 400 and 500 K, which are also present due to formamide decomposition (cf. Section III.B). The ruthenium-carbon bond of adsorbed CO is formed by electron donation from the 5σ (carbon lone pair) orbital of CO to the surface, accompanied by electron back-donation from the metal sd-band to the $2\pi^*$ antibonding orbital of CO.¹⁸ The (relatively) electronegative nitrogen adatoms withdraw electron density from the surface ruthenium atoms, presumably reducing the extent of the back-bonding and leading to a lowered CO desorption temperature. A similar effect has been observed for CO that is coadsorbed with ordered overlayers of oxygen adatoms on Ru-(001).19

The saturation coverage of CO on Ru(001) is known to be approximately 0.68 monolayer.²⁰ Since all of the formamide that decomposes on the Ru(001) surface gives rise to CO as a reaction product, there is a one-to-one correspondence between the amount of CO that desorbs for a given formamide coverage and the amount of formamide that decomposes. Thus, by comparing the time-integrated intensities of the CO thermal desorption peaks for saturation exposures of both CO and NH₂CHO, the amount of NH₂CHO that decomposes for a saturation formamide exposure may be calculated. This comparison yields an estimate of 0.15



Figure 4. Thermal desorption spectra of H_2 (m/e = 2 amu) that result following various exposures of NH₂CHO to the clean Ru(001) surface at 80 K. The inset compares H₂ thermal desorption spectra that result following saturation exposures of H₂ and NH₂CHO on this surface. The approximate formamide exposures are (a) 0.5 L, (b) 1 L, (c) 2 L, (d) 4 L, and (e) 10 L.

monolayer of irreversibly adsorbed NH₂CHO following a saturation formamide exposure on Ru(001) at 80 K, or approximately 2.3×10^{14} molecules-cm⁻².

3. Hydrogen. Figure 4 shows a series of H_2 (m/e = 2 amu) thermal desorption spectra that were measured following various NH₂CHO exposures to Ru(001) at 80 K, as well as the H₂ thermal desorption spectrum that results following a saturation exposure of H_2 on Ru(001). For an exposure of 0.5 L of formamide there is a single desorption peak at 420 K, which shifts downward with increasing exposures. This is a second-order desorption peak resulting from the recombinative desorption of hydrogen adatoms, since the H_2 thermal desorption spectra that result from 0.5-1-L formamide exposures are nearly identical with those that result from low H_2 exposures on Ru(001), where the adsorption is dissociative and the desorption is second-order.²¹ For a 2-L NH₂CHO exposure, the single H₂ desorption peak has downshifted to 395 K. Following a 4-L exposure, three peaks appear at 325, 380, and 405 K. Finally, a 10-L exposure (slightly greater than saturation) gives rise to a rather complex desorption spectrum, with the three previously mentioned peaks now at 300, 375, and 410 K and a fourth peak at 280 K.

Thermal desorption spectra of H_2 , HD, and D_2 following saturation exposures of ND₂CHO on Ru(001) (not shown) were also measured in order to determine the origin of the hydrogen desorbing in the four peaks of Figure 4e. The 410 K peak consisted almost entirely of D_2 with a small amount of HD, indicating that the hydrogen desorbing in this peak originates primarily, if not entirely, from the NH₂ group of the formamide. (It should be recalled that a small amount of NHDCHO and/or NH₂CHO was present in the ND₂CHO sample.) The peak at 375 K was very rich in HD and contained no D_2 . Sample contamination precluded a quantitative analysis of the relative amounts of H₂, HD, and D_2 desorbing in each peak.

Since the saturation coverage of hydrogen adatoms on Ru(001) is known to be approximately 0.85,²¹ and the amount of NH₂CHO that decomposes following a saturation exposure on Ru(001) is known to be approximately 0.15 from the CO thermal desorption data discussed above, the H₂ thermal desorption spectra may be

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Figure 5. The m/e = 14 amu (N cracking fragment of N₂) thermal desorption spectrum that results following a saturation exposure of NH₂CHO to the clean Ru(001) surface at 80 K.



Figure 6. Thermal desorption spectra for m/e = 17 amu that result when the Ru(001) surface at 80 K is exposed to approximately (a) 0.4 L, (b) 2 L, (c) 5 L, and (d) 8 L of formamide. Only the high-temperature feature corresponds to ammonia desorption; the peak at 235 K is due to a molecular formamide cracking fragment.

used to estimate very approximately the amount of NH_3 that is formed and desorbed following a saturation formamide exposure. The hydrogen thermal desorption spectra indicate that approximately 0.39 monolayer of hydrogen adatoms are desorbed as H_2 , corresponding to the decomposition of 0.13 monolayer of NH_2 -CHO. The amount of ammonia that is desorbed is thus approximately 0.15 - 0.13 = 0.02 monolayer. Although the absolute accuracy of this estimate is poor (probably no better than a factor of 2), it is clear that the amounts of H_2 and CO that desorb are in a ratio of nearly 3:2, so that most of the formamide that decomposes must produce only CO, H_2 , and N_2 as desorption products. The amount of NH_3 that is desorbed is quite small, and the formation of NH_3 represents a minor reaction pathway.

4. Nitrogen. Figure 5 shows the m/e = 14 amu (N cracking fragment of N₂, which distinguishes it from CO) thermal desorption spectrum that results following a saturation exposure of NH₂CHO on Ru(001) at 80 K. Nitrogen is desorbed between approximately 555 and 810 K, with a maximum desorption rate near 685 K. For a 0.5-L NH₂CHO exposure, the nitrogen desorbs with a peak temperature of approximately 770 K. The fact that molecularly adsorbed N₂ on Ru(001) desorbs below 150 K²² and the clear evidence for the presence of nitrogen adatoms in EEL spectra measured following NH₂CHO adsorption and annealing to above 400 K (cf. Section III.B) prove unambiguously that this desorption of N₂ results from the recombinative desorption of



Figure 7. The EEL spectra that result following 0.5-L exposures of (a) NH₂CHO and (b) ND₂CHO to the clean Ru(001) surface at 80 K. These spectra are characteristic of $\eta^2(C,O)$ -NH₂CO and $\eta^2(C,O)$ -ND₂CO.

nitrogen adatoms that are formed from the decomposition of formamide.

5. Ammonia. Thermal desorption spectra for m/e = 17 amu following various exposures of formamide to the Ru(001) surface at 80 K are shown in Figure 6. Thermal desorption spectra of mass 18 were also measured, and the lack of water desorption verifies that the desorption peaks in Figure 6 do not correspond to an OH cracking fragment of desorbed H_2O . However, the 235 K thermal desorption peak appears at the same temperature and coverage as a molecular formamide thermal desorption peak and appears to be due entirely to a formamide cracking fragment. Thus, only the desorption peak at 285-315 K is due to ammonia desorption. Ammonia desorption is observed for all formamide exposures, which ranged from 0.3 L to saturation. At low coverage, the peak temperature is 315 K, and it shifts down in temperature to 285 K when this peak is saturated. Since ammonia is identified clearly with EELS (cf. Figure 8) this ammonia desorption peak appears to be mainly desorption-limited. The initial desorption temperature of 315 K is in agreement with the results of a previous, detailed study of ammonia adsorption on clean Ru(001), in which it was shown that ammonia desorbed in a single peak centered at 315 K for initial ammonia coverages less than approximately 15% of saturation.¹⁴ The total amount of ammonia that desorbs following a saturation formamide exposure is estimated to be ≤ 0.02 monolayer, based on the previously discussed CO and H₂ thermal desorption measurements. Essentially all of the ammonia that is formed desorbs rather than decomposes.¹⁴

B. Electron Energy Loss Spectroscopy. In discussing the EEL spectra of NH₂CHO on Ru(001), it is convenient to consider separately two distinct coverage regimes. For low initial coverages (exposures <2 L, where the amount of NH₂CHO that decomposes is less than approximately 0.05 monolayer), only a single surface species is detected by EELS following adsorption at 80 K. For higher coverages (exposures >2 L, where the amount of formamide decomposing is greater than approximately 0.05 monolayer), an additional surface species is present at 80 K due to the passivation of the surface by the products of the initial adsorption reaction. The low and high coverage regimes are thus treated separately below.

1. Low Coverage. The EEL spectra that result following 0.5-L exposures of NH₂CHO and ND₂CHO to the clean Ru(001) surface at 80 K are shown in Figure 7. In both spectra there is a weak loss feature near 2000 cm⁻¹ due to ν (CO) of a very small amount (<0.005 monolayer) of coadsorbed CO. This CO is adsorbed from the chamber background and is not due to form-amide decomposition. In addition, the ND₂CHO spectrum shows a weak ν (NH) loss feature at 3380 cm⁻¹ due to a small amount

⁽²²⁾ See ref 19 above, as well as: Anton, A. B.; Avery, N. R.; Toby, B. H.; Weinberg, W. H. J. Electron Spectrosc. Relat. Phenom. 1983, 29, 181.

of NHDCHO and/or NH_2CHO contamination. The other loss features in both spectra disappear concomitantly upon annealing to approximately 250 K and may therefore be assigned to a single surface species that is formed upon the adsorption of formamide at 80 K.

For a number of reasons, the species present on the surface at 80 K may be identified as NH_2CO . First, both spectra of Figure 7 show no evidence of a carbon-hydrogen stretching mode in the 2800-3100-cm⁻¹ region, and corresponding spectra measured off-specular also show no evidence of a ν (CH) mode. The latter measurement is of importance because $\nu(CH)$ modes are often detected most easily in off-specular EEL spectra.¹ Since the ν (CH) mode is clearly detected in several formamide-derived species (including the parent molecule) on the $Ru(001)-p(1\times 2)-O$ surface,² it is concluded that carbon-hydrogen bond cleavage has occurred upon the adsorption of formamide at 80 K. Second, since there are no vibrational modes in either spectrum due to oxygen adatoms,²³ nitrogen adatoms (see Figure 9c), or CO (other than a trivial amount of CO adsorbed from the chamber background), it is apparent that the carbon-nitrogen and carbon-oxygen bonds of formamide remain intact. This conclusion is justified since our previous studies of formamide decomposition on Ru(001)-p(1× 2)-O show that loss features due to carbon monoxide and atomic oxygen are easily detected in the presence of coadsorbed formamide and its decomposition products.² Third, the clear presence of two nitrogen-deuterium stretching modes in the ND₂CHO spectrum, the NH₂ wagging mode at 820 cm⁻¹ which shifts down to approximately 600 cm⁻¹ upon N-deuteriation and the mode at 1580 cm⁻¹ in the NH₂CHO spectrum which shifts down markedly upon N-deuteriation [indicating that this mode has substantial $\delta(NH_2)$ character], all indicate that the NH₂ bonds are not broken. Taken together, these arguments serve to identify the species that is present on the surface as NH₂CO. Such a species may be either $\eta^1(C)$ -bonded,³ $\eta^2(C,O)$ -bonded,⁵ or $\eta^2(C,N)$ -bonded⁷ (cf. Figure 1, illustrations 1, 3, and 5b). However, $\eta^2(C,N)$ -OCNH₂ species in organometallic compounds exhibit strong $\nu(CO)$ modes near 1775 cm⁻¹,⁷ and all organometallic analogues of $\eta^1(C)$ -CONH₂ exhibit strong ν (CO) stretching modes between 1500 and 1650 cm^{-1} .³ Since these modes are clearly lacking in Figure 7b, the surface species is identified as $\eta^2(C,O)$ -NH₂CO. Since the carbon-oxygen bond of the $\eta^2(C,O)$ -NH₂CO has undergone substantial rehybridization, its bond order is significantly less than two. The precise carbon-oxygen and carbon-nitrogen bond orders are somewhat indeterminate, however, since several resonance structures may be drawn for this surface species (cf. Section IV). It might be noted in passing that the observation of two metalligand stretching frequencies (see below) is another argument that the surface species present is not $\eta^1(C)$ -CONH₂.²⁴ It should be pointed out that hydrogen adatoms are also present on the surface together with the $\eta^2(C,O)$ -NH₂CO, but they are not detected by EELS due to their very weak loss features.

Due to substantial coupling among several vibrational modes of $\eta^2(C,O)$ -NH₂CO and $\eta^2(C,O)$ -ND₂CO, a complete mode assignment is not possible without the benefit of a normal mode analysis. However, several of the observed loss features may be assigned unambiguously. The peaks at 270 (270) and 360 (370) cm⁻¹ in the case of $\eta^2(C,O)$ -NH₂CO ($\eta^2(C,O)$ -ND₂CO) are both assigned to ruthenium–NH₂CO stretching modes. The peak at 820 cm⁻¹ in Figure 7a shifts down to approximately 600 cm⁻¹ upon N-deuteriation, so that it overlaps with the peak at 655 cm⁻¹, forming a single broad feature centered at 615 cm⁻¹. As stated above, the 820-cm⁻¹ peak is thus identified as the NH₂ wagging mode, $\omega(NH_2)$, and the peak at 655 cm⁻¹ is identified as the NCO bending mode, $\delta(NCO)$. The peak at 3370 cm⁻¹ in Figure 7a is due to the unresolved $\nu_s(NH_2)$ and $\nu_a(NH_2)$ modes, while in the case of $\eta^2(C,O)$ -ND₂CO, $\nu_s(ND_2)$ and $\nu_a(ND_2)$ occur at 2455 and

Table I. Frequencies (cm⁻¹) of the Observed Vibrational Modes of $\eta^2(C,O)$ -NH₂CO and $\eta^2(C,O)$ -ND₂CO on Ru(001)

mode	$\eta^2(C,O)$ -NH ₂ CO	$\eta^2(C,O)$ -ND ₂ CO	freq shift
$\nu_{a}(\mathrm{NH}_{2})$		2560	~1.32
a 2/	3370 ^b		
$\nu_{\rm s}(\rm NH_2)$		2455	~ 1.37
see text ^a	1580, 1370	1440, 1285	
	1300, 1015	1085, 980	
$\omega(\mathrm{NH}_2)$	820	$\sim 600^{c}$	~1.37
δ(NCO)	655	$\sim 650^{c}$	~1.01
$\nu(Ru-NH_2CO)$	360	370	0.97
	270	270	1.00

^a Coupling among these four modes precludes specific mode assignments. The (uncoupled) modes involved are $\nu_s(NCO)$, $\nu_a(NCO)$, δ -(NH₂), and $\rho(NH_2)$. ^b This feature is broad, and the $\nu_a(NH_2)$ and ν_s -(NH₂) modes are not resolved clearly. ^c These two modes overlap in the case of $\eta^2(C,O)$ -ND₂CO.

Table II. Frequencies (cm⁻¹) and Mode Assignments for Liquid NH₂CHO, Liquid ND₂CHO, and Gas-Phase NH₂CHO^a

mode	NH ₂ CHO(1) ⁴³	ND ₂ CHO(1) ⁴³	NH ₂ CHO(g) ⁴⁴
$\nu_{\rm a}(\rm NH_2)$	3330	2556	3545
$\nu_{\rm s}(\rm NH_2)$	3190	2385	3451
v(CH)	2882	2887	2852
$\nu(CO)$	1690	1667	1734
$\delta(NH_2)$	1608	1118	1572
δ(CH)	1391	1398	1378
$\nu(CN)$	1309	1338	1255
$\pi(CH)$	1056	1056	1030
$\rho(\rm NH_2)$	1090	912	1059
$\omega(NH_2)$	750	450	602
$\tau(\rm NH_2)$	200		289
δ(NCO)	608	570	565

a = asymmetric, s = symmetric.

2560 cm⁻¹, respectively. Four additional peaks appear in each spectrum, at 1015, 1300, 1370, and 1580 cm⁻¹ for $\eta^2(C,O)$ -NH₂CO and at 980, 1085, 1285, and 1440 cm⁻¹ for $\eta^2(C,O)$ -ND₂CO. In the case of $\eta^2(C,O)$ -NH₂CO, four modes are expected between 1000 and 1600 cm⁻¹, as observed: the symmetric and asymmetric NCO stretching modes, and the NH₂ scissoring and rocking modes. However, coupling among these four modes is evidently significant and renders the mode descriptions $v_s(NCO)$, $\nu_a(\text{NCO}), \delta(\text{NH}_2), \text{ and } \rho(\text{NH}_2) \text{ rather meaningless. We note$ again, however, that the 1580-cm⁻¹ mode in Figure 7a must have substantial $\delta(NH_2)$ character, since the highest of these four "middle frequency modes" of $\eta^2(C,O)$ -ND₂CO occurs at a frequency 140 cm⁻¹ lower than this. The observed vibrational frequencies and partial mode assignments for $\eta^2(C,O)$ -NH₂CO and $\eta^2(C,O)$ -ND₂CO are summarized in Table I. For comparison, Table II provides vibrational frequencies and mode assignments for liquid and gas-phase formamide.

The EEL spectra of low coverages of formamide adsorbed on clean Ru(001) at 80 K show that $\eta^2(C,O)$ -NH₂CO remains on the surface when the surface is annealed briefly to temperatures below approximately 230 K, at which point decomposition of the $\eta^2(C,O)$ -NH₂CO begins. The only change in the EEL spectra for annealing temperatures below 230 K is that following annealing to 200 K the $\omega(NH_2)$ mode [$\omega(ND_2)$ in the case of $\eta^2(C,O)$ -ND₂CO] increases in intensity by approximately a factor of 2, while the intensities of the other vibrational modes of $\eta^2(C,O)$ -NH₂CO remain essentially constant. This suggests a reorientation of the NH₂ group as the surface is heated. The intensity of the $\omega(NH_2)$ mode is expected to be greatest when it involves motion of the NH₂ hydrogen atoms that is largely perpendicular to the surface.²⁵

Annealing the Ru(001) surface on which low coverages of $\eta^2(C,O)$ -NH₂CO are present to 250 K causes the vibrational features due to $\eta^2(C,O)$ -NH₂CO to disappear completely, leaving the EEL spectrum shown in Figure 8a. This EEL spectrum is

⁽²³⁾ Thomas, G. E.; Weinberg, W. H. J. Chem. Phys. **1978**, 69, 3611. (24) An additional argument against $\eta^1(C)$ -NH₂CO is the fact that this ligand is known in organometallic chemistry only in compounds containing a single metal atom. When more than one metal atom is present, the observed bonding configuration is $\eta^2(C,O)$ -NH₂CO or, more rarely, $\eta^2(C,N)$ -OCNH₂. See ref 3, 5, and 7.

⁽²⁵⁾ This is a consequence of the so-called surface dipole selection rule. See Chapters 1 and 3 of ref 1.



Figure 8. (a) The EEL spectrum that results when the Ru(001) surface represented in Figure 7a is annealed briefly to 250 K. (b) The EEL spectrum that results when the clean Ru(001) surface at 80 K is exposed to approximately 1 L of NH₃ and annealed to 300 K.

Table III. Summary of Vibrational Frequencies (cm⁻¹) and Mode Assignments for the Decomposition Products of $\eta^2(C,O)$ -NH₂CO on Ru(001) after Annealing to 250-300 K

species	mode	freq	species	mode	freq
CO	ν(CO)	1985	NH	$\nu(\rm NH)$	3315
	$\nu(Ru-CO)$	460		$\delta(NH)$	1350
NH_3	$\nu(\mathrm{NH}_3)^a$	3315		$\nu(Ru-NH)$	690
-	$\delta_a(NH_3)$	1590			
	$\nu_{\rm s}(\rm NH_3)$	1160			

^a The $\nu_s(NH_3)$ and $\nu_a(NH_3)$ modes of adsorbed NH₃ are not resolved from the $\nu(NH)$ mode of coadsorbed NH.

characterized by intense peaks at 460, 1160, and 1985 cm⁻¹ and by weak peaks at approximately 690, 1350, 1590, and 3315 cm⁻¹. The intense peaks at 460 and 1985 cm⁻¹ are identified easily as $\nu(RuC)$ and $\nu(CO)$ of carbon monoxide adsorbed in on-top sites.^{20,26} On the basis of a comparison to an EEL spectrum of ammonia adsorbed on the Ru(001) surface at 80 K and annealed briefly to 300 K ($\theta_{\rm NH_3} \sim 0.02$ -0.03 monolayer) (Figure 8b), the peaks at 1160, 1590, and (in part) 3315 cm⁻¹ are identified as being due to adsorbed ammonia. Previous EELS studies of NH_3 adsorbed on Pt(111),²⁷ Ag(110),²⁸ Ni(111),²⁹ Ni(110),²⁹ and Fe(110)³⁰ have yielded very similar EEL spectra, and these modes are assigned as $\delta_s(NH_3)$, $\delta_a(NH_3)$, and $\nu(NH_3)$, respectively. Finally, the modes at 690 and 1350 cm⁻¹, and part of the intensity of the 3315-cm⁻¹ mode, are due to a third surface species that is identified as adsorbed NH. The mode assignments for this species are the following: $\nu(NH)$, 3315 cm⁻¹; $\delta(NH)$, 1350 cm⁻¹; and $\nu(Ru-NH)$, 690 cm⁻¹ (see below). Thus the three spectroscopically isolated decomposition products of $\eta^2(C,O)$ -NH₂CO on Ru(001) are CO, NH₃, and NH.³¹ The mode assignments of the EEL spectrum of Figure 8a are summarized in Table III.

When the Ru(001) surface on which $\eta^2(C,O)$ -ND₂CO is adsorbed is annealed to 250 K, the CO modes are again observed at 460 and 1985 cm⁻¹. Rather than a single sharp and intense peak at 1160 cm⁻¹, however, four overlapping peaks are observed between 900 and 1160 cm⁻¹ due to the symmetric deformation mode of four different ammonia isotopes: ND₃, ND₂H, NDH₂,

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Figure 9. (a) The EEL spectrum that results when the Ru(001) surface represented in Figure 7a is annealed briefly to 350 K. (b) An EEL spectrum of the same surface measured 10° off-specular. (c) The EEL spectrum that results when the surface represented in Figure 7a is annealed briefly to 500 K.

and NH₃. The observed frequencies are 900 cm⁻¹ (ND₃), 990 cm⁻¹ (ND₂H), 1090 cm⁻¹ (NDH₂), and 1160 cm⁻¹ (NH₃). The major species formed is ND₂H, and substantial amounts of ND₃ are also formed. (A crude estimate based on the intensities of the symmetric deformation modes is that the ratio of ND₂H to ND₃ is approximately 3:2). A ν (ND) loss feature is present at 2450 cm⁻¹, and a weak ν (NH) loss feature is present at 3295 cm⁻¹. The ν_a modes of the various ammonia isotopes, as well as the $\nu(ND)$ mode of coadsorbed ND, are not well resolved. However, an ND species is undoubtedly present and contributes to the intensity of the $\nu(ND)$ loss feature.

Annealing the surface represented by Figure 8a to 350 K causes the adsorbed ammonia to desorb molecularly, leaving only CO and NH in subsequent EEL spectra³¹ and allowing a more definitive characterization of the NH species. Figure 9a shows the specular EEL spectrum of the surface following annealing to 350 K, while Figure 9b shows the EEL spectrum of the same surface, but measured 10° off-specular toward the surface normal. The importance of the off-specular spectrum is that it allows the weak ν (Ru–NH) mode of adsorbed NH at 690 cm⁻¹ to be resolved much more clearly from the tail of the elastic peak that is attenuated more rapidly than the loss peaks in off-specular measurements. Note that annealing from 250 K (Figure 8a) to 350 K (Figure 9a) causes the integrated intensity of the $\nu(NH)$ mode at 3315 cm⁻¹ to decrease by only approximately 40%, indicating that the NH does indeed contribute significantly to the intensity of this mode in Figure 8a. Table IV lists the vibrational modes of adsorbed NH and compares them to those of the adsorbed NH species identified previously as a product of hydrazine decomposition on Ni(111).³² The observed $\delta(NH)$ frequency of 1350 cm⁻¹ is well within the range of 1200-1420 cm⁻¹ observed for $\delta(NH)$ in organic imides.³³ Table IV also lists the vibrational

^{(26) (}a) Thomas, G. E.; Weinberg, W. H. J. Chem. Phys. 1979, 70, 1437. (b) References 12 and 20.

⁽²⁷⁾ Sexton, B. A.; Mitchell, G. E. Surf. Sci. 1980, 99, 523.
(28) Gland, J. L.; Sexton, B. A.; Mitchell, G. E. Surf. Sci. 1982, 115, 623.
(29) Fisher, G. B.; Mitchell, G. E. J. Electron Spectrosc. Relat. Phenom.

^{1983. 29. 253}

⁽³⁰⁾ Erley, W.; Ibach, H. Surf. Sci. 1982, 119, L357.

⁽³¹⁾ Hydrogen adatoms are also present on the surface but are not detected by EELS due to their small cross section for inelastic scattering.^{21d} (32) Glant, J. L.; Fisher, G. B.; Mitchell, G. E. Chem. Phys. Lett. 1985,

^{119, 89.}

^{(33) (}a) Bigotto, A.; Galasso, V. Spectrochim. Acta 1979, 35A, 725. (b) Woldback, T.; Klaeboe, P.; Christensen, D. H. Acta Chem. Scand. 1976, A30, 531.

frequencies of the various modes of ND formed from ND₂CHO decomposition on Ru(001), which are the following: ν (ND), 2460 cm⁻¹; δ (ND), 1050 cm⁻¹; and ν (Ru-ND), 680 cm⁻¹. The corresponding vibrational frequencies of ND on Ni(111) are listed as well.

Annealing the Ru(001) surface to just over 400 K results in the decomposition of NH, leaving only CO, nitrogen adatoms, and a small amount of hydrogen adatoms on the surface. The nitrogen adatoms are identified by a loss feature at 580 cm⁻¹ due to the vibration of these atoms perpendicular to the surface, i.e., $v_s(RuN)$. This mode appears as a shoulder on the $v_s(RuC)$ mode of coadsorbed carbon monoxide, when the latter is present. Annealing to 500 K desorbs the CO (and all remaining hydrogen), leaving only nitrogen adatoms on the surface (Figure 9c). The $v_s(RuN)$ mode of the nitrogen adatoms remains present (and of nearly constant intensity) in EEL spectra after the surface is annealed to 700 K and then attenuates and disappears as the surface is annealed to just over 800 K, in agreement with the N₂ thermal desorption results for low coverages of formamide.

2. High Coverage. For initial formamide exposures at 80 K that are greater than approximately 2 L (but below the exposures necessary to condense formamide multilayers), both $\eta^2(C,O)$ -NH₂CO and molecular formamide are observed as adsorption products with EELS. The molecular formamide is $\eta^1(O)$ -NH₂CHO, the same species that is formed following formamide adsorption at 80 K on the Ru(001)-p(1×2)-O surface.² Although many of the loss features due to $\eta^1(O)$ -NH₂CHO overlap to some degree the loss features due to $\eta^2(C,O)$ -NH₂CO, the $\nu(CO)$ loss peak of the former species is quite strong and is resolved clearly at 1670 cm⁻¹, and the $\nu(CH)$ loss peak is also observed at 2895 cm⁻¹. The frequency of $\nu(CO)$ indicates that the CO double bond is maintained in the molecularly adsorbed formamide.

The decomposition of $\eta^1(O)$ -NH₂CHO³⁴ is difficult to monitor with EELS, since $\eta^2(C,O)$ -NH₂CO and/or its decomposition products are always present as well, depending on the annealing temperature. Indeed, for a saturation formamide exposure, the $\eta^2(C,O)$ -NH₂CO is stabilized by the higher surface coverage, and a small amount is present to 290 K. As on $Ru(001)-p(1\times 2)-O^{2}$, the $\eta^1(O)$ -NH₂CHO that is formed undergoes competing desorption and conversion to another surface species at 225 K for a sufficiently high initial exposure (4 L or greater). For formamide exposures between 2 and 4 L, only decomposition of $\eta^1(O)$ -NH₂CHO is observed. This new surface species is stable to approximately 300 K, but it is not easily identifiable due to the presence of several other species on the surface in this temperature range. However, this intermediate does exhibit vibrational loss features at 1675 cm⁻¹ [ν (CO)] and 2920 cm⁻¹ [ν (CH)] and lacks the strong $\omega(NH_2)$ loss feature at 970 cm⁻¹ which characterizes $\eta^2(N,O)$ -NH₂CHO on the Ru(001)-p(1×2)-O surface.² These vibrational features probably cannot be attributed to $\eta^1(O)$ -NH₂CHO, which, if it does not convert to another species, desorbs well below 300 K. The possible nature of this intermediate, which is identified tentatively as $\eta^1(N)$ -NHCHO, will be discussed in Section IV.

Annealing the formamide saturated Ru(001) surface to temperatures in the range of 300 to 350 K causes all of the $\eta^2(C, O)$ -NH₂CO to decompose and all of the ammonia that is formed to desorb, leaving a much simpler EEL spectrum. Identical EEL spectra are obtained if formamide is adsorbed on Ru(001) at room temperature and annealed to 350 K to desorb residual ammonia (cf. Figure 10). (Subsequent exposure to D₂ does not alter these spectra significantly.) The species detected in such EEL spectra include CO, NH, and a small amount of nitrogen adatoms.³¹ More significantly, a new surface species is detected which must arise from the decomposition of $\eta^1(O)$ -NH₂CHO via the unidentified intermediate discussed in the previous paragraph. This new species maintains the carbon-hydrogen bond as indicated by a ν (CH) loss feature at 2940 cm⁻¹ and shows a loss feature at 1770



Figure 10. The EEL spectrum that results when the clean Ru(001) surface at 300 K is exposed to 2 L of NH_2CHO and annealed briefly to 350 K.

 $\rm cm^{-1}$ that is characteristic of a carbonyl double bond in which the oxygen atom is not coordinated to the metal atom via an electron lone pair donor bond. The new species is thus identified as containing a formyl (HCO) group. Three such species must be considered in determining the identity of this intermediate: η^{1} -(C)-HCO (η^1 -formyl, which could be formed from carbon-nitrogen bond cleavage of formamide), $\eta^1(N)$ -NHCHO, and η^1 -(N)-NCHO. The possibility of η^1 -formyl formation can be ruled out since all η^1 -formyl ligands identified in organometallic compounds have a $\nu(CO)$ frequency between 1540 and 1614 cm^{-1,35} more than 150 cm⁻¹ lower than the frequency of 1770 cm⁻¹ observed in the present case. In addition, η^1 -formyl is not observed as a decomposition product of formaldehyde on Ru(001),¹⁰ so its formation from formamide is not expected, especially above 300 K. On the other hand, $\eta^1(N)$ -NHCRO ligands identified in organometallic compounds have $\nu(CO)$ frequencies between 1708 and 1758 cm^{-1,4} in good agreement with the present data, and an $\eta^1(N)$ -NCHO species would be expected to have a similar ν (CO) frequency. A definite distinction between η^1 (N)-NHCHO and $\eta^1(N)$ -NCHO is not possible because the presence of significant amounts of coadsorbed NH in the EEL spectrum of Figure 10 makes it impossible to determine whether or not the intermediate gives rise to a nitrogen-hydrogen stretching vibration. We tentatively prefer $\eta^1(N)$ -NCHO over $\eta^1(N)$ -NHCHO, because we believe that the latter species is present below 300 K and would probably undergo NH bond cleavage below 375 K. The identification of this intermediate as $\eta^1(N)$ -NCHO would allow all the loss features in Figure 10 to be identified as follows. The intense loss features at 430 and 2000 $\rm cm^{-1}$ are due to carbon monoxide, while the features at 3280 and (in part) 1380 $\rm cm^{-1}$ are due to NH. The weak feature at 565 cm⁻¹ indicates that a small amount of NH has decomposed, leaving nitrogen adatoms on the surface. The remaining loss features can be attributed to vibrational modes of $\eta^1(N)$ -NCHO: $\nu(CH)$, 2940 cm⁻¹; $\nu(CO)$, 1770 cm⁻¹; π (CH), 1150 cm⁻¹; δ (NCO), 760 cm⁻¹; and ν_s (RuN), 340 cm⁻¹. The peak at 1380 cm⁻¹ is quite broad and probably derives intensity from $\delta(CH)$ and $\nu(CN)$ of $\eta^1(N)$ -NCHO as well as from $\delta(NH)$ of coadsorbed NH, since this peak is more intense [relative to the v(NH) peak] than would be expected if only NH were present. As the surface is annealed to progressively higher temperatures, the loss features at 2940, 1770, 1150, 760, and 340 cm⁻¹ attenuate and disappear in unison, verifying that they are due to a single surface species. The EEL spectrum of Figure 10 is thus fully consistent with the presence of an $\eta^1(N)$ -NCHO species.

Further annealing of the formamide saturated Ru(001) surface

⁽³⁴⁾ An unknown amount of $\eta^{I}(O)$ -NH₂CHO also desorbs at 225 K, so that this species undergoes competing desorption and decomposition following exposures $\gtrsim 4 L$.

^{(35) (}a) Gladysz, J. A.; Tam, W. J. Am. Chem. Soc. 1978, 100, 2545. (b) Tam, W.; Wong, W.; Gladysz, J. A. J. Am. Chem. Soc. 1979, 101, 1589. (c) Winter, S. R.; Cornett, G. W.; Thompson, E. A. J. Organomet. Chem. 1977, 133, 339. (d) Gladysz, J. A.; Williams, G. M.; Tam, W.; Johnson, D. L. J. Organomet. Chem. 1977, 140, C1. (e) Gladysz, J. A.; Selover, J. C. Tetrahedron Lett. 1978, 319. (f) Collins, T. J.; Roper, W. R. J. Chem. Soc., Chem. Commun. 1976, 1044.

to 375 K causes the $\eta^1(N)$ -NCHO to dissociate to carbon monoxide, nitrogen adatoms, and (by inference) hydrogen adatoms, so that only these species and NH remain on the surface. In contrast to the low coverage data, EEL spectra show that some NH is still present on the surface at 400 K, but that it decomposes completely by 430 K. The desorption of CO (and all remaining hydrogen) is complete below 500 K, leaving only nitrogen adatoms on the surface which are manifest in EEL spectra by $v_s(RuN)$ at 580 cm⁻¹. The recombinative desorption of N_2 is complete by 810 K, leaving the clean Ru(001) surface following annealing to this temperature.

An additional issue of importance is the branching ratio for the two observed decomposition mechanisms of formamide on Ru(001), i.e., of the approximately 0.15 monolayer of formamide that decomposes following a saturation exposure, how much decomposes via $\eta^2(C,O)$ -NH₂CO and how much via $\eta^1(O)$ -NH₂CHO and $\eta^1(N)$ -NCHO? This branching ratio may be estimated by using the intensity of the 2000-cm⁻¹ carbon monoxide loss peak following annealing to 300 K, since by this temperature all the $\eta^2(C,O)$ -NH₂CO has decomposed to CO and either NH or NH₃, while little if any of the $\eta^1(N)$ -NCHO has yet decomposed. This estimate makes use of the known coverage versus intensity relationship for this CO loss feature.²⁰ The resulting estimate is that approximately 0.10 monolayer of formamide decomposes via the $\eta^2(C,O)$ -NH₂CO intermediate, while the remaining approximately 0.05 monolayer decomposes via η^{1} -(N)-NCHO.

Finally, as discussed in Section III.A.1, exposing the clean Ru(001) surface at 80 K to approximately 8 L or more of NH₂CHO results in the condensation of molecular multilayers of formamide, which desorb when the surface is annealed to 210 K. As expected, these multilayers are identical with those formed on the Ru(001)-p(1×2)-O surface.^{2b}

IV. Discussion

It has been shown that the adsorption of low coverages of formamide on clean Ru(001) (i.e., where the amount of formamide that decomposes is less than 0.05 monolayer) at 80 K results in CH bond cleavage and rehybridization of the carbonyl double bond to produce an $\eta^2(C,O)$ -NH₂CO species and a hydrogen adatom. No other surface species is identified by EELS below 230 K. The only thermal desorption products detected for these low formamide exposures (≤2 L) are CO near 480 K, H₂ near 420 K, N₂ near 770 K, and NH_3 near 315 K. The CO and NH_3 result from molecular desorption, while the H₂ and N₂ result from the recombinative desorption of hydrogen and nitrogen adatoms.

The structure and bonding of the $\eta^2(C,O)$ -NH₂CO is of considerable interest since such a species has not been identified previously on a metal surface. Unfortunately, the lack of a definitive mode assignment due to the presence of significant mode coupling places limits on the conclusions that can be drawn. Several organometallic analogues have been synthesized and characterized, but vibrational data are scarce. In most of these $\eta^2(C,O)$ -NR₂CO ligands, the CO and CN bond orders are less than two and greater than one, so that substantial mode coupling occurs between $\nu(CO)$ and $\nu(CN)$, making the mode descriptions $v_{s}(NCO)$ and $v_{a}(NCO)$ more meaningful. A series of mononuclear uranium and thorium compounds have been synthesized with the metal-formide group represented by the resonance structures shown below.5a



M = U or Th, R = alkyl; additional ligands not shown

These compounds have $v_a(NCO)$ frequencies between 1491 and 1559 cm⁻¹ and $\nu_{\rm s}$ (NCO) frequencies between 1298 and 1346 cm⁻¹. Also relevant to $\eta^2(C,O)$ -NH₂CO on Ru(001) are the $\eta^2(C,-$ O)-NR₂CO ligands in several trinuclear ruthenium^{5c,e} and osmium^{5b,d} complexes, the structures of which have been represented as follows:



M = Ru or Os, R = alkyl; additional ligands not shown

Although IR data with mode assignments are not available for these compounds, X-ray structures show clearly that both the CO and CN bonds of the OCN group have bond lengths intermediate between those expected for single and double bonds. For example, the OCN(CH₃)₂ ligand in HRu₃(OCN(CH₃)₂)(CO)₁₀ has CO and CN bond lengths of 1.287 and 1.340 Å,^{5c} respectively, while "typical" C=O, C-O, C=N, and C-N bond lengths are approximately 1.22, 1.43, 1.27, and 1.47 Å, respectively.³⁶ We expect that the structure of $\eta^2(C,O)$ -NH₂CO on Ru(001) is similar to the structures observed for the $\eta^2(C,O)$ -NR₂CO ligands in these trinuclear ruthenium and osmium complexes, and indeed the rehybridization of the CO bond may occur to an even greater extent on the extended ruthenium surface due to the following additional resonance structure:



The species most closely related to $\eta^2(C,O)$ -NH₂CO that has been identified previously on Ru(001) is $\eta^2(C,O)$ -HCO (η^2 formyl), which is formed (along with chemisorbed CO and hydrogen adatoms) following relativly low exposures of formaldehyde to this surface at 80 K.¹⁰ The η^2 -formyl has a ν (CO) frequency of 1180 cm⁻¹, indicative of a CO bond order of approximately 1.3. In this case, the assignment of $\nu(CO)$ is straightforward and meaningful, because coupling to the CH bending modes is insignificant. (The mode identified as $\nu(CO)$ shifts down only slightly to 1160 cm⁻¹ upon deuteriation of the formyl.) The decomposition of $\eta^2(C,O)$ -NH₂CO is similar to that of η^2 -formyl on Ru(001) in that carbon monoxide is the only oxygen- or carbon-containing decomposition product. The $\eta^2(C,O)$ -NH₂CO is considerably more stable than η^2 -formyl, however, since the latter decomposes to carbon monoxide and hydrogen adatoms upon annealing to only 120 K. The fact that formamide can undergo CH bond cleavage at 80 K on Ru(001) is not surprising in view of the fact that formaldehyde does. The CH bond energies of these two molecules are similarly low: 87 kcal in formaldehyde³⁷ and 89 kcal in formamide.38

The spectroscopically observed decomposition products of η^2 -(C,O)-NH₂CO, appearing in the temperature range 230-250 K, are CO, NH₃, and NH. Additional hydrogen adatoms also result from the decomposition of this species, since very little ammonia $(\leq 0.02 \text{ monolayer})$ is produced. The rate-limiting step in this decomposition is almost certainly CN bond cleavage to produce NH₂ and CO, because if NH bond cleavage preceded CN bond cleavage, NH_3 would probably not be formed.³⁹ Since NH_2 is not observed spectroscopically, it is concluded that this species is unstable on Ru(001) at 250 K (on the time scale of seconds at these surface coverages) and rapidly dehydrogenates to NH or is hydrogenated by a hydrogen adatom to NH₃. The ammonia that is produced desorbs molecularly at 315 K, in agreement with previous studies of ammonia adsorption on Ru(001).^{14a}

The NH species observed on Ru(001) from formamide decomposition is only the second NH species that has been identified spectroscopically on a metal surface. The first was NH formed from hydrazine decomposition on Ni(111),³² and Table IV shows

⁽³⁶⁾ The "typical" bond lengths are estimated from covalent radii. See:
Jolly, W. L. The Principles of Inorganic Chemistry; McGraw-Hill: New York, 1976; p 36.
(37) Golden, D. M.; Benson, S. W. Chem. Rev. 1969, 69, 125.
(38) Kahumoto, T.; Saito, K.; Imamura, A. J. Phys. Chem. 1985, 89, 2286.

⁽³⁹⁾ Preliminary experiments with coadsorbed NH and hydrogen and coadsorbed ammonia and hydrogen suggest that NH cannot be hydrogenated to ammonia on Ru(001) under UHV conditions, and also that deuterium adatoms do not exchange into adsorbed ammonia. Parmeter, J. E., unpublished results.

that the vibrational frequencies of the two species are quite similar. Since the only examples known to us of NH ligands in organometallic complexes are in complexes containing at least three metal atoms with the nitrogen atom in a threefold hollow site among three metal atoms,⁴⁰ it is very likely that NH on Ru(001) occupies threefold hollow sites as well. This is undoubtedly also true of the NH on Ni(111), a surface that has the same hexagonally close-packed structure as Ru(001).

The decomposition of ND₂CHO on Ru(001) leads to the formation of chemisorbed ammonia, with ND₂H and ND₃ being formed in an approximate ratio of 3:2. We suspect that the minor amounts of NDH₂ and NH₃ that are formed result from sample contamination by NHDCHO and NH₂CHO. The adsorption at 80 K of pure ND₂CHO would produce $\eta^2(C,O)$ -ND₂CO and hydrogen adatoms. Decomposition of $\eta^2(C,O)$ -ND₂CO would then produce (presumably) a short-lived ND₂ species, which would either dehydrogenate to ND with the production of a deuterium adatom or be hydrogenated to ammonia by a hydrogen adatom or, in some cases, by a deuterium adatom formed from ND_2 decomposition to ND. Since there will be more hydrogen adatoms present on the surface than deuterium adatoms, the ammonia that is formed would be mainly ND_2H with a smaller amount of ND_3 . The formation of some NDH, could conceivably result from H/D exchange into ND_2H , but preliminary results suggest that this reaction should not occur under these conditions.³⁹ As expected, the "NH" formed from ND₂CHO decomposition is almost entirely ND, and the small amount of NH formed may result from sample contamination or from H exchange into ND.

For sufficiently high formamide exposures $(\geq 2 L)$ to the Ru-(001) surface at 80 K, molecularly adsorbed $\eta^1(O)$ -NH₂CHO is observed in EELS in addition to $\eta^2(C,O)$ -NH₂CO. This indicates that the initial products of adsorption, $\eta^2(C,O)$ -NH₂CO and hydrogen adatoms, passivate the surface with respect to subsequent CH bond cleavage and CO bond rehybridization so that at higher coverages the molecularly adsorbed $\eta^1(O)$ -NH₂CHO species is formed as on the Ru(001)-p(1×2)-O surface.² A similar but more complex situation occurs in the case of formaldehyde adsorption on Ru(001), where the following adsorption products appear sequentially with increasing exposure at 80 K: CO + 2H, η^2 -(C,O)-HCO + H, η^2 (CO)-H₂CO, and η^1 (O)-H₂CO.¹⁰ In the case of formamide adsorption on Ru(001) at 80 K, no $\eta^2(C,O)$ -NH₂CHO species is detected unambiguously for intermediate formamide exposures, which might have been expected from the formaldehyde results. It is possible, however, that such a species is formed in small amounts, but that its loss features cannot be resolved from those of the other surface species that are present.

The $\eta^1(O)$ -NH₂CHO decomposes completely upon annealing for formamide exposures less than 4 L (amount of formamide decomposing less than approximately 0.10 monolayer), whereas for exposures greater than 4 L it undergoes competing desorption and decomposition at 225 K. While we have no quantitative estimate of the amount of $\eta^1(O)$ -NH₂CHO that desorbs molecularly, the amount that decomposes following a saturation formamide exposure is approximately 0.05 monolayer. Two stable decomposition intermediates are observed in the decomposition of $\eta^1(O)$ -NH₂CHO, one that is present from approximately 225 to 300 K and the second from 300 to 375 K. The species that is stable from approximately 300 to 375 K is probably $\eta^1(N)$ -NCHO, analogous to the NH species formed from $\eta^2(C,O)$ -NH₂CO decomposition, but with the hydrogen atom replaced by a formyl group. This species decomposes to CO, nitrogen adatoms, and hydrogen adatoms upon annealing the surface to 375 K. The first intermediate, present from 225 to 300 K, contains a carbon-oxygen double bond $[\nu(CO) = 1675 \text{ cm}^{-1}]$ and a carbonhydrogen bond $[\nu(CH) = 2920 \text{ cm}^{-1}]$, but it lacks the intense $\omega(NH_2)$ loss feature at 970 cm⁻¹ that characterizes $\eta^2(N,O)$ - NH_2CHO on $Ru(001)-p(1\times 2)-O^2$, a species that is formed on that surface by conversion of $\eta^1(O)$ -NH₂CHO at 225 K and which is bonded to the surface via electron lone pairs on both the oxygen and nitrogen atoms. While the identification of this intermediate is uncertain, it seems likely that the coordination of the nitrogen atom to the surface must occur at 225 K in order to lead to the eventual formation of $\eta^1(N)$ -NCHO. We suggest that on Ru(001) this occurs via nitrogen-hydrogen bond cleavage to produce an N-bonded NHCHO species that maintains the carbonyl double bond and the donor bond between the oxygen atom and the metal surface, as shown below:



This species could convert to $\eta^1(N)$ -NCHO at 300 K by simultaneously undergoing cleavage of the remaining nitrogen-hydrogen bond and the oxygen-ruthenium donor bond. It is not clear in detail, however, why such an N-bonded NHCHO species would not convert to the formate-like species $\eta^2(N,O)$ -NHCHO [cf. Figure 1, species 4], which is formed upon nitrogen-hydrogen bond cleavage of $\eta^2(N,O)$ -NH₂CHO at 265 K on Ru(001)-p(1×2)-O.² In general, the answer undoubtedly lies largely in the differing electronic properties of the Ru(001) and Ru(001)-p(1×2)-O surfaces.

A final issue to be addressed is the complex nature of the hydrogen thermal desorption spectra. For a saturation formamide exposure, the following reactions produce hydrogen adatoms as the surface is heated [assuming the presence of both N-bonded NHCHO and NCHO intermediates in $\eta^1(O)$ -NH₂CHO decomposition]:

$$NH_{2}CHO(g) \xrightarrow{80 \text{ K}} \eta^{2}(C,O) \cdot NH_{2}CO + H + \eta^{1}(O) \cdot NH_{2}CHO (i)$$

$$\eta^{1}(O)-NH_{2}CHO \xrightarrow{223 \text{ K}} NHCHO + H$$
 (ii)

 $\eta^{2}(C,O)$ -NH₂CO $\xrightarrow{230-290 \text{ K}}$ CO + NH + H (or CO + NH₃) (iii)

NHCHO
$$\xrightarrow{300 \text{ K}} \eta^1(\text{N})$$
-NCHO + H (iv)

$$\eta^{1}(N)$$
-NCHO $\xrightarrow{375 \text{ K}}$ CO + N + H (v)

$$NH \xrightarrow{375-430 \text{ K}} N + H \qquad (vi)$$

Here (g) denotes a gas-phase species, and all other species are adsorbed. If we consider a saturation exposure of ND₂CHO and neglect contamination by NHDCHO or NH2CHO, reactions i and v will produce hydrogen adatoms, while reactions ii, iii, iv, and vi will produce deuterium adatoms.⁴¹ Although the four hydrogen desorption peaks at 280, 300, 375, and 410 K (cf. Figure 4) cannot be assigned exclusively to surface hydrogen produced by any single reaction listed above, several conclusions can be drawn. First, since NH decomposes above 375 K, the hydrogen produced by NH decomposition must desorb in the 410 K peak (with perhaps a small amount desorbing in the 375 K peak). Indeed, the desorption of hydrogen at 300 K is a minor piece of evidence supporting the decomposition of $\eta^1(N)$ -NHCHO to $\eta^1(N)$ -NCHO at this temperature. This scheme is also in agreement with thermal desorption results for ND2CHO that show the 410 K peak to contain mainly D_2 , a result that shows the hydrogen in this peak is derived largely from the ND₂ group of the initially adsorbed formamide. Some HD also desorbs at 410 K since not all of the hydrogen adatoms formed by reaction v desorb immediately in the 375 K peak. Thus, while not all hydrogen in the 410 K peak results from NH decomposition, it is NH decomposition near 410 K that increases the surface hydrogen (H or D) adatom concentration and serves to trigger this intense

^{(40) (}a) Fjare, D. E.; Gladfelter, W. L. J. Am. Chem. Soc. 1981, 103, 1572. (b) Fjare, D. E.; Gladfelter, W. L. Inorg. Chem. 1981, 20, 3533.

⁽⁴¹⁾ This analysis also assumes that no H/D exchange occurs among the various adsorbed surface species.

desorption peak. Similarly, the desorption of hydrogen at 280, 300, and 375 K is probably triggered by reactions iii, iv, and v, respectively.⁴² Indeed, the desorption of hydrogen at 300 K is a minor piece of evidence supporting the decomposition of η^1 -(N)-NHCHO to η^1 (N)-NCHO at this temperature. This scheme is also consistent with large amounts of HD in the 375 K peak (cf. Section III.A.3), since reaction v produces hydrogen adatoms that will recombine with adatoms on the surface, and the latter will be primarily deuterium rather than hydrogen. We emphasize once again that the problem of sample contamination (and, to a lesser degree, the difficulty of peak deconvolution) makes a more quantitative analysis of the amounts of H_2 , HD, and D_2 desorbed in each peak impossible.

V. Conclusions

Following a saturation formamide exposure on the clean Ru-(001) surface at 80 K, approximately 0.15 monolayer of formamide decomposes. This decomposition occurs via two distinct mechanisms. The major one, accounting for 0.10 monolayer of formamide that decomposes at saturation, is the only decomposition mechanism that occurs at low coverage and may be written as follows (the temperatures given are for the low coverage limit, and the second step is clearly not elementary):

$$NH_{2}CHO(g) \xrightarrow{80 \text{ K}} \eta^{2}(C,O) \cdot NH_{2}CO + H$$
$$\eta^{2}(C,O) \cdot NH_{2}CO \xrightarrow{230-250 \text{ K}} CO + NH + H + NH_{3}$$
$$NH_{3} \xrightarrow{315 \text{ K}} NH_{3}(g)$$
$$CO \xrightarrow{480 \text{ K}} CO(g)$$
$$NH \xrightarrow{350-400 \text{ K}} N + H$$
$$2H \xrightarrow{420 \text{ K}} H_{2}(g)$$
$$2N \xrightarrow{770 \text{ K}} N_{2}(g)$$

(42) The fact that an H_2 thermal desorption peak occurs at 300 K following saturation exposures supports the idea of a dehydrogenation reaction occurring at this temperature and thus, indirectly, supports the presence of an N-bonded NHCHO species which converts to an N-bonded NCHO species.

(43) Suzuki, I. Bull. Chem. Soc. Jpn. 1960, 33, 1359.
(44) (a) Evans, J. C. J. Chem. Phys. 1954, 22, 1228. (b) King, S. T. J. Phys. Chem. 1971, 75, 405.

Table IV. Vibrational Frequencies (cm⁻¹) and Mode Assignments for NH and ND on Ru(001) (This Work) and Ni(111)³²

· · · ·	Ru(001)		Ni(111)			
mode	NH	ND	Shift	NH	ND	Shift
$\nu(\rm NH)$	3315	2460	1.35	3340	2480	1.35
δ(NH)	1350	1050	1.29	1270	950	1.34
ν(M-NH)	690	680	1.01	620	580	1.07

At saturation, approximately 0.08 monolayer of NH and 0.02 monolayer of NH_3 are produced.

For exposures greater than 2 L, where the amount of formamide that decomposes is greater than approximately 0.05 monolayer, a second decomposition mechanism occurs. In this mechanism, $\eta^1(O)$ -bonded molecular formamide, formed from formamide adsorption at 80 K, converts near 225 K to an intermediate believed to be an N-bonded NHCHO species. At 300 K, this intermediate converts to an intermediate tentatively identified as $\eta^1(N)$ -NCHO, a species analogous to NH but with the hydrogen atom replaced by a formyl group. This intermediate decomposes near 375 K to coadsorbed carbon monoxide, and nitrogen and hydrogen adatoms. For exposures greater than 4 L, where the amount of formamide that decomposes is greater than approximately 0.09 monolayer, some molecular desorption of $\eta^1(O)$ -NH₂CHO occurs also at 225 K.

The reactions and surface intermediates observed in formamide decomposition on clean Ru(001) and on Ru(001)- $p(1\times 2)$ -O are quite different. However, $\eta^1(O)$ -NH₂CHO is formed on both surfaces under certain conditions of coverage and temperature. The amount of formamide that decomposes following a saturation exposure increases by a factor of 3, from 0.05 to 0.15 monolayer, in going from the oxygen covered to the clean surface.

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Registry No. NH₂CHO, 75-12-7; Ru, 7440-18-8; NH₃, 7664-41-7; CO, 630-08-0.

Resonance Raman Spectroscopic Study of Bilirubin Hydrogen Bonding in Solutions and in the Albumin Complex

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Abstract: Resonance Raman spectra are reported for bilirubin in chloroform, dimethyl sulfoxide, and aqueous solutions, and for the 1:1 bilirubin/albumin complex and the bilirubin complexes of α - and β -cyclodextrin. From the known hydrogen-bonding patterns in the several free solutions, Raman markers for the presence or absence of internal hydrogen bonding are derived. From equilibrium and time-resolved deuteration, partial assignments of the spectra are proposed. The resonance Raman spectrum of the bilirubin/albumin complex demonstrates that the internal hydrogen bonds between propionate groups and the pyrromethenone rings are ruptured. Propionate hydrogen bonding is to amino acid residues of the protein only.

(4Z, 15Z)-Bilirubin IX α (structure 1a), commonly called bilirubin, is the final product of hemoglobin metabolism.¹ The molecule is only sparingly soluble in aqueous solutions, although

the dipropionate anion (structure 1b) is soluble in alkaline solution. Bilirubin is carried through the bloodstream to the liver as an albumin complex. In the liver the water-soluble glucuronic acid ester is formed. Bilirubin diglucuronide is then transported to the kidneys and excreted in the urine.

Historically, bilirubin has been considered as merely a toxic waste product² with an interesting chemistry. If bilirubin is not

^{(1) (}a) Heirweigh, K. P. M.; Brown, S. B., Eds. Bilirubin; CRC Press: Boca Raton, FL, 1982; Vol. I. (b) McDonagh, A. F. In The Porphyrins; Dolphin, D., Ed.; Academic Press: New York, 1979; Vol. 6, pp 293-491.